Review Article

DNA Damage and Repair in Plants under Ultraviolet and Ionizing Radiations

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Being sessile, plants are continuously exposed to DNA-damaging agents present in the environment such as ultraviolet (UV) and ionizing radiations (IR). Sunlight acts as an energy source for photosynthetic plants; hence, avoidance of UV radiations (namely, UV-A, 315–400 nm; UV-B, 280–315 nm; and UV-C, <280 nm) is unpreventable. DNA in particular strongly absorbs UV-B; therefore, it is the most important target for UV-B induced damage. On the other hand, IR causes water radiolysis, which generates highly reactive hydroxyl radicals (OH•) and causes radiogenic damage to important cellular components. However, to maintain genomic integrity under UV/IR exposure, plants make use of several DNA repair mechanisms. In the light of recent breakthrough, the current minireview (a) introduces UV/IR and overviews UV/IR-mediated DNA damage products and (b) critically discusses the biochemistry and genetics of major pathways responsible for the repair of UV/IR-accrued DNA damage. The outcome of the discussion may be helpful in devising future research in the current context.

1. Introduction

Having sessile nature, plants have to cope with constant exposure of environmental stressors which includes UV-B, ozone, desiccation, rehydration, salinity, low and high temperature, and air and soil pollutants including metals–metalloids. Several chemical mutagens and crosslinking agents (e.g., mitomycin C, cisplatin), alkylating agents, aromatic compounds, ionizing radiations, and fungal and bacterial toxins are included as the other important environmental DNA-damaging agents [1]. Apart from severely impacting plant structural, enzymatic and nonenzymatic components, the aforesaid stressors may also negatively threaten plant genomes. Despite the very stable nature of plant genome, nuclear DNA is an inherently unstable molecule and can be damaged spontaneously, metabolically, or by aforesaid stress factors. The overproduction of reactive oxygen species (ROS) as byproducts of normal cellular metabolism or as a result of abiotic stress conditions leads to DNA damage in the cell [2, 3]. In addition to producing both single-strand DNA breaks (SSBs) and double-strand DNA breaks (DSBs), intrinsic DNA damage may include the loss of a base to form an abasic site, chemical modification of a base to form a miscoding or noncoding lesion, and sugar–phosphate backbone breakage [4, 5]. The accumulation of such damages (unrecognized and unrepaired DNA damage) may cause lethal mutations which in turn can reduce plant genome stability, growth, and productivity and also threaten the organism’s immediate survival [2, 3, 5–7]. Therefore, effective detection of DNA damage, removal of damaged nucleotides, replacement with undamaged nucleotides via DNA synthesis, and repair of DNA damage are essential to eliminate the chance of permanent genetic alterations and hence to ensure the stability of the plant genome [2, 7, 8].
2. Ultraviolet (UV), Ionizing Radiations (IR), and Cellular DNA

Plants, because of their sessile nature, are especially susceptible to damage caused by environmental factors. Though sunlight is obligatory for photosynthesis and survival of plants, it also represents one of the major threats to their genomic integrity. Sunlight contains energy rich UV-A (320–400 nm), UV-B (290 to 320 nm), and UV-C (280 to 100 nm) light. UV-C is filtered out in the atmosphere and UV-B and UV-A can reach earth’s surface effectively [3]. Among UV radiation types, UV-A radiation has been shown to have less DNA damaging effect because it cannot be absorbed by native DNA, whereas UV-A and visible light energy (up to 670–700 nm) can damage DNA via indirect photosensitizing reactions-mediated ROS generation especially singlet oxygen \((^{1}O_{2})\) [9]. UV-C radiation does not show much harmful effects on the biota since it is quantitatively absorbed by oxygen and ozone in the Earth’s atmosphere. In the past 50 years, the concentration of ozone has decreased by about 5% (hence significant depletion in stratospheric ozone), mainly due to the release of anthropogenic pollutants such as chlorofluorocarbons [10]. Consequently, a larger proportion of the UV-B spectrum reaches the Earth’s surface with serious implications on all living organisms [11–17].

UV-B radiation reaching the earth’s surface is highly variable and influenced by many factors including stratospheric ozone layer and geographical area. Though most of the extraterrestrial UV-B is absorbed by the stratospheric ozone, remaining UV-B can produce adverse effects on diverse habitats [18]. Anthropogenically released chlorine and fluorine-containing compounds (e.g., CFCs) mediate significant depletion of stratospheric ozone which is basically responsible for increased UV-B radiation in the past decades in particular in the Antarctic zone [11, 12, 16, 17]. Although UV-B radiation has less than 1% of total solar energy, it is a highly active component of the solar radiation that brings chemical modification in DNA [19, 20]. UV radiation is one of the most damaging agents for DNA and other biomolecules such as proteins and lipids [21, 22]. Moreover, cellular DNA has been considered an obvious key target for UV induced genetic damage in a variety of organisms including plants [1, 23]. Mechanism of DNA damage and repair in response to UV/IR radiation has been shown in Figure 1.

On the perspective of IR mediated DNA damage in plants, it causes water radiolysis, which generates highly reactive \(\text{OH}^{\cdot}\) radicals. \(\text{OH}^{\cdot}\) radicals are the most reactive among all ROS and known to react with all biological molecules like DNA, proteins, lipids, and almost any constituent of cells. In the absence of any enzymatic mechanism for the removal of \(\text{OH}^{\cdot}\), excess \(\text{OH}^{\cdot}\) accumulation ultimately leads to cell death. DNA is the most preferred biomolecule being attacked by both the \(\text{OH}^{\cdot}\) and the UV radiations (i.e., there is both direct and indirect effect) [24]. A number of alterations like SSBs and DSBs may take place in the IR and free radicals targeted DNA [24]. Plants may recruit a wide variety of strategies to either reverse, excise, or tolerate the presence of DNA damage products [5]. In this perspective, though mechanisms underlying UV and ionizing radiations-mediated DNA damage and repair have been thoroughly described in bacteria, yeast, and mammalian systems, information on these processes in plants is scanty and unsubstantiated. However, the DNA damage under UV radiation and DNA repair associated enzymes have been shown to greatly modulate the mutation rate, chromosome aberration frequencies, and viability in seeds and seedlings [25].

The following sections and subsections present an overview on UV/ionizing radiation-mediated DNA damage products and critically discuss potential, biochemical, and genetic mechanisms underlying UV/ionizing radiation accrued DNA damage and repair pathways.

3. UV-B Radiation Accrued DNA Damage

UV-B radiation can penetrate and damage plant genome by inducing oxidative damage (pyrimidine hydrates) and cross-links (both DNA protein and DNA-DNA) that are responsible for retarding the growth and development of plants [1, 6, 26, 27]. UV-B radiation damages nuclear, chloroplast, and mitochondrial DNA by inducing various DNA lesions including the generation of cyclobutane pyrimidine dimers (CPDs) (as the primary UV-B-induced DNA lesions accounting approximately 75% of UV-B-mediated total DNA damage) and other photoproducts, pyrimidine (6–4) pyrimidone dimers as the major lesions, while the minor includes oxidized or hydrated bases, single-strand breaks, and others [28, 29].

On the perspective of the production of different types of structural distortions within DNA due to CPDs and 6–4PPs, the induction of a slight bending on the DNA helix has been evidenced due to CPDs, whereas, 6–4PPs can produce much more bending and also unwinding on the DNA [1]. These DNA lesions together can act as the principal cause of UV-B-induced growth inhibition in plants. Additionally, these products can be lethal or mutagenic to organisms and can also impede transcriptional processes and result in error-prone replication [30–33]. Indirect generation of reactive oxygen species (ROS) due to solar UV light has also been evidenced in the nucleus [34]. Nevertheless, ROS-accrued base and nucleotide modifications, especially in sequences with high guanosine content, and also strand breaks have been widely reported and reviewed [6, 30, 35, 36].

3.1. Cyclobutane Pyrimidine Dimer. Cyclobutane pyrimidine dimer (CPD) is a major type of DNA damage induced by UV-B radiation. CPDs constitute the majority of these lesions (approximately 75%). Herein, any of the diastereoisomers such as cis/trans (relative position of pyrimidine rings) and syn-anti (relative orientation of C5–C6 bonds) can be formed. Moreover, though cis-syn forms of CPDs are of common occurrence, trans-syn forms are present exclusively within single-stranded DNA [1, 37]. No or very low amounts of CPDs have been evidenced due to low UV-B rates \((<1 \mu\text{mol m}^{-2} \text{s}^{-1})\) which though below the limit of detection, stimulate protective and photomorphogenetic responses [38, 39], eventually affecting the plant’s resistance to UV-B stress [15, 28, 38].
Major lesions

Single strand breaks (SSBs); double strand breaks (DSBs); hydrolytic depurination, apyrimidinic sites

Cyclobutane pyrimidine dimers (CPDs)

Pyrimidine (6-4) pyrimidone dimers

DNA damage

Maintenance of the genome integrity and viability of plants

Repair pathways

Light-dependent repair (photoreactivation/photorepair)

Light-independent repair (dark repair)

Nonhomologous recombination

Homologous recombination

Figure 1: Mechanism of DNA damage and repair in plants.
3.2. Pyrimidine (6-4) Pyrimidone Dimers. Pyrimidine (6-4) pyrimidone dimers (6-4PPs dimers) are other major lesions caused by UV-B radiation. However, the occurrence of 6-4PPs dimers is much less frequent than CPDs [6, 40]. The UV radiation wavelength and sequence dependent formation of the 6-4PPs at adjacent TT, TC, and CC nucleotides has also been evidenced [1]. To this end, in addition to being impacted by UV-B, 6-4PP dimers are photoisomerized by UV-A light resulting in the Dewar isomer [37, 40].

3.3. Ionizing Radiation and DNA Damage. A number of alterations may take place in the IR and free radicals targeted DNA like single-strand breaks and double-strand breaks, and hydrolytic depurination, apyrimidinic sites, and oxidative damage to the bases and the phosphodiester backbone of DNA are common [24, 41]. Gamma irradiation with different dose rates induces different DNA damage responses in Petunia × hybrida cells [42]. Double-strand breaks (DSBs) are a strikingly genotoxic form of DNA damage; hence, DSBs present a unique challenge to the cell. The failure to repair a break in DNA has been widely evidenced to cause loss of a chromosome arm where misrepair can produce translocations, deletions, and other chromosomal abnormalities [43, 44]. In addition, unrepaired breaks in dividing cells can initiate cell cycle checkpoints, halting division, and, consequently, slowing the growth of the organism [45]. However, the production of aneuploid daughter cells (that are often not viable) has been reported as nondividing cells [46, 47]. The developmental regulation of DSB repair mechanisms in plants has also been evidenced [48]. The occurrence of multiple pathways for the repair of DSBs has been reported in plants [49]. Some of the major pathways for DSB-repair in plants will be overviewed in the following sections.

4. DNA Damage-Repair Pathways

The repair of DNA damage is essential for the survival of organisms while, if repair does not take place, genomic integrity will not be maintained [50]. To this end, coordination between DNA replication and repair has been considered essential for the maintenance of the genome [51]. The UV radiation induced DNA damage and repair has been well studied but concrete information on the underlying mechanisms in plant system is still lacking [51].

Information pertaining to the dynamics of DNA damage accumulation and molecular mechanisms that regulate recovery from radiation injury as a function of dose rate is unsubstantiated and poorly explored [24, 42]. Nevertheless, the information to date available in the current context indicates that a mechanism of DNA damage repair in plants is very complex which actually involves multiple loci. Additionally, involvement of mechanisms—either similar or identical to those regulating the integrity of foreign sequences in the plant genomes—has been reported [24]. In addition, plant response to IR may also involve the activation of cell cycle checkpoints which subsequently may lead to the DNA repair response [52]. The studies on γ-rays on Populus nigra var. italic a revealed that the modulation of repair mechanisms is essential for the adaptive response to IR [53]. Chronic or acute irradiation exposed Arabidopsis thaliana plants exhibited differential regulation of gene expression of DNA repair machinery [54]. It is to be underlined here that the DNA damage contributed by either UV and/or IR can be corrected employing a number of pathways such as direct repair, photorepair (photoreactivation), base excision repair (BER), nucleotide excision repair (NER), or mismatch repair (MMR) in plants where abovementioned lesion-specific repair pathways can reverse UV/IR-induced DNA damage to preserve the genomic integrity [55–58]. The significance of the replicative arrest avoidance has also been evident in plants as a potential mechanism for UV photoproducts-tolerance. Moreover, implication of genes isolated from the model plant A. thaliana in nucleotide excision repair or tolerance of UV-induced DNA damage was a possible result of phenotypic characterization of plant mutants, functional complementation studies, and cDNA analysis [57].

Major mechanisms underlying coping strategies for UV-B/IR-induced DNA damage are being overviewed hereunder.

4.1. Light-Dependent Repair (Photoreactivation/Photorepair). The photorepair (photoreactivation) is the major pathway in plants for repairing UV-B induced low frequencies of DNA damage (especially of UV-B induced CPDs) where the photolyase mediate the major processes by absorbing blue/UV-A (320–400 nm) light and uses the energy to monomerize dimers [1, 59–62]. There exist similar reaction mechanisms underlying both CPD photolyases and 6-4 photolyases-mediated repair of the respective pyrimidine dimers [40, 63]. The occurrence of the reduced pterin MTHF in plant-CPD photolyase activity as the second chromophore has been evidenced [64]. Photolyases bind specifically to DNA lesions and efficiently and quickly remove the bulk of UV-induced CPDs and (6-4)-photoproducts directly by absorbing light in the 300–600 nm range [27, 65, 66]. A number of cofactors including the quality, timing, and quantity of photoreactivating light and damage levels largely modulate this repair [60, 65, 67]. Different genotypes exhibiting sensitivity to UV-B were reported to exhibit differential ability to repair UV-B-mediated DNA damage types (such as CPDs), where UV-B = sensitive cultivars were less able to repair CPDs through photoreactivation than UV-B resistant cultivars [68].

To date, photoreactivation and photolyases have been extensively reported in several plant species [65–77]. However, credible work has been performed on Oryza sativa cultivars, where photolyase has been evidenced as a major factor modulating O. sativa cultivar capability to repair DNA damage types [68, 76–79]. Earlier also, the sensitivity of O. sativa to UV-B radiation was reported to vary among cultivars [78]. Based on the exhibition of O. sativa cultivars potential for the level of CPD photolyase activity, O. sativa cultivars were clearly classified into three groups, which in turn depended on amino acid residues at positions 126 (UV-B resistant O. sativa, glutamine; UV-B sensitive and UV-B hypersensitive O. sativa, arginine) and 296 (UV-B resistant}
and UV-B sensitive *O. sativa*, glutamine; UV-B hypersensitive, histidine) [68]. It was also postulated that increasing the activity of the photolyase enzyme in *O. sativa* may increase their resistance to UV-B radiation [68, 77, 79]. In some recent reports, UV-B sensitive *O. sativa* cultivars were evidenced to exhibit less capability to repair CPDs through photoreactivation than UV-B resistant cultivars, where the authors considered an alteration of CPD photolyase activity resulting from spontaneously occurring mutations in the CPD photolyase gene [68, 77, 79]. Transgenic *O. sativa* plants have also been successfully generated bearing the CPD photolyase gene from UV-B resistant *O. sativa* cultivars [68, 80]. Overexpression of CPD photolyase in *O. sativa* results in higher CPD photolyase activity which resulted in significant more resistance to UV-B induced growth damage than wild-type plants. In contrast, plants with the gene transferred in the antisense orientation had significantly lower CPD photolyase activity and showed less resistance to UV-B radiation. Recently, Teranishi et al. [68] developed CPD photolyase overexpressing transgenic *O. sativa* plants with higher CPD photolyase activity using UV-B sensitive *O. sativa* Norin 1 (japonica) and UV-B hypersensitive *O. sativa* Surjamkhi (indica) as parental line (PL) plants. These results emphasized that CPD photolyase is a crucial factor for determining UV-B sensitivity in *O. sativa* [68, 80]. In addition to the studies on *O. sativa*, the overexpression of CPD photolyase in *A. thaliana* also resulted in a moderate increase in biomass production under conditions of elevated UV-B radiation [17]. Moreover, an ecotype-specific genetic variability in the UV-B response in *A. thaliana* has also been evidenced [81].

4.2. Light-Independent Repair (Dark Repair). The dark repair includes nucleotide excision repair (NER), base excision repair (BER), mismatch repair (MMR), and other DNA repair pathways. Excision repair (NER and BER) is very important for maintaining genome stability and essential for the survival of organisms. The potential mechanisms underlying dark repair reactions have been discussed earlier extensively [40, 82, 83]. The occurrence of light-independent repair pathway has been evidenced in a number of plant species including carrot protoplasts [84, 85], *A. thaliana* [86], alfalfa seedlings [59, 65], soybean chloroplasts and leaves [60, 87], *O. sativa* cultivars [61], and *Triticum aestivum* leaf tissues [88] (reviewed by Brit et al. [71] & Tuteja et al. [6]). Despite the availability of biochemical and genetic data in favor of some sort of NER in plants, limited information is available concerning the molecular characterization of plant gene products actively involved in dark repair [62]. Compared to the light-dependent repair (photoreactivation/photorepair), more general and flexible feature has been evidenced by the light-independent repair (dark repair) where the recognition and targeting of the damaged strand and subsequent removal of a 24–32 base oligonucleotide containing the damaged product and filling the gap through DNA synthesis and ligation of the nicks have been reported [89, 90]. In context with NER, this system has been considered the most versatile system for dealing with the DNA damage [91]. Since NER recognizes conformational changes in the DNA duplex rather than a specific type of DNA damage, this system can also repair different types of damage [25]. Moreover, NER comprises the two subpathways, namely, global genomic repair (GGR) and transcription-coupled repair (TCR), where GGR repairs the DNA damage over the entire genome and TCR is selective for the transcribed DNA strand in expressed genes [51]. The wide class of helix-distorting lesions such as CPDs and (6-4) photoproducts are repaired by NER [6, 27]. The sequential involvement of NER-mediated recognition of DNA damage, incision on damaged strand, excision of damage containing oligonucleotides, DNA synthesis, and ligation has been reported [51]. The conserved nature of the NER repair pathway has been proved by revealing most of the genes involved in NER in *A. thaliana* [92].

BER also comprises the two subpathways, namely, the short-patch BER and long-patch BER, where the former is DNA polymerase (beta-dependent) and the latter is DNA polymerase (delta/epsilon-dependent). BER repairs the oxidized or hydrated bases and SSB. Herein, DNA glycosylases initiate this process by releasing the damaged base, with cleavage of the sugar phosphate chain, excision of a basic residue or of a basic residue containing oligonucleotides, and DNA synthesis and ligation has been reported [51]. The conserved nature of the BER repair pathway has been proved by revealing most of the genes involved in BER in *O. sativa* and *A. thaliana* have also been reported [51, 97–99].

Insertions or deletions of nucleotides (potential frame shift mutations) may be more frequent, where nucleotide-repeat sequences can give rise to slip-mispairing [100]. Additionally, the mismatched bases also arise during recombination. However, the mismatch repair (MMR) systems have been evolved to correct a large portion of these errors, further reducing the error rate 10⁻⁹ to 10⁻¹⁰ [101]. The promotion of genomic stability by highly conserved MMR systems via the correction of DNA replication errors, antagonizing homologous recombination and responding to various DNA lesions, has been widely evidenced [101]. MMR mechanism is highly conserved between species where it removes majority (99.9%) of the errors remaining after polymerase proofreading to reduce the error rate to one misincorporated base per 10⁸–10⁹ nucleotides in the nascent DNA chain. Moreover, MMR may also recognize mismatches at sites of recombination between DNA sequences; thereby it can reduce the rate of occurrence of recombination events [101, 102]. Encoding a suite of MMR protein orthologs, including MSH2, the constant component of various specialized eukaryotic mismatch recognition heterodimers has been reported in *A. thaliana* and other plants [101].

4.3. Double-Strand Breaks Repair. Double-strand breaks (DSBs) have to be eliminated before genomes can be replicated; hence, genomic DSBs have been regarded as key
intermediates in recombination reactions of living organisms. Nevertheless, the efficient repair of genomic DNA-DSBs is important for the survival of all organisms [103, 104]. Though the studies on DSBs repair in animals and yeast have been credibly performed, this aspect in plants lags behind [44]. In recent years, basic mechanisms of DSB repair in somatic plant cells have been elucidated. In addition, homologous recombination (HR) and the nonhomologous system (NHR) are the two general classes of recombination to perform DSBs-repair. The availability of complete sequences of A. thaliana and O. sativa has intensified efforts to characterize endogenous regulatory components of HR and nonhomologous end joining (NHEJ) [92]. HR and NHR-assisted repair of double-strand DNA breaks has been reported to control the viability under irradiation [104, 105]. Both HR and NHR/NHEJ pathways are responsible for balancing genome stability against the generation of genetic diversity. Additionally, the essential roles of HR and NHEJ have been considered vital for genetic engineering [44]. Moreover, there are credible reports on the (a) isolation of radiation-sensitive plant mutants [27, 40, 106, 107] and (b) successful cloning of many plant genes from different repair pathways involved in repair of radiation-induced damage [108–III] but to date, the efficiency of NER and DSB repair and the stability/modification of these systems under chronic irradiation conditions have not been reported [25]. Some of the specific features and overall significance of these two DSB-repair pathways (i.e., HR and NHEJ) are highlighted hereunder.

4.4. Homologous Recombination. HR has been considered as the major pathway for maintaining the genome integrity and viability of plants where it performs mainly the error-free DSB-repair. HR uses a homologous chromosome or chromatid as a template to recover information [43]. Moreover, in HR, the double-stranded gap generated by a frayed DSB is filled by copying, or in some cases splicing, homologous sequences from elsewhere in the genome [44]. A credible work in yeast has led to the categorization of models pertaining to HR into three models: DNA double-strand break repair (DSBR) model, synthesis-dependent strand annealing (SSDA), and single-strand annealing (SSA) [40, 112, 113]. In brief, both DSBR and SSA are initiated by a 3’ resection forming a long single-stranded DNA tail that invades a homologous duplex and primes DNA synthesis but in SSDA, the newly synthesized DNA then reanneals with the other side of the DSB, repairing the break and avoiding the formation of the joint molecule [40]. SSA may occur between tandemly repeated sequences and anneal homologous regions exposed during resection. A number of plant species have been evidenced to possess DSBR, SSDA, and SSA HR pathways exhibiting much of the common molecular machineries, where recombination frequencies were reported to greatly vary from the origin of the donor and recipient sequences [40, 104, 114]. Very rare (around 1 in 10,000 repair events) occurrence of HR-mediated DSB repair has been reported in plant somatic cells via allelic sequences [115].

On the perspective of molecular mechanism of HR, a number of researchers including [40, 114, 116] reported or reviewed sharing of similarities in meiotic and somatic recombination pathways at the molecular level. Central to the process of homologous recombination are the RAD52 epistasis group genes (RAD50, RAD51, RAD52, RAD54, RDH54/TIDI, RAD55, RAD57, RAD59, MRE11, and XRS2), most of which were identified by their requirement for the repair of IR-induced DNA damage in yeast. The contribution of mutations in these genes was evidenced to cause defects in meiotic and/or mitotic recombination and thus has provided evidence for a link between DSB repair (DSBR) and HR [117]. Among these genes, owing to severe meiotic defects, A. thaliana HR null mutants such as AtRAD51, AtRAD50, and AtMRE11 were reported to be completely sterile [108, 118]. In addition, meiocytes of these mutant lines were evidenced to show extensive chromosome fragmentation leading ultimately to nonviable gametes because of the incapability of these mutants to align homologous chromosomes (synapsis) during the early stages of meiosis [108, 118]. Rad54 has been isolated and characterized from A. thaliana, where its significance in HR was advocated [119]. A weaker expression of Rad54 has been evidenced earlier in irradiated A. thaliana when compared to nonirradiated plants. A plant homolog of Nijmegen breakage syndrome-1 gene from Arabidopsis (AtNbs1) and O. sativa (OsNbs1) has been identified and their involvement in DNA/DSB repair was evidenced [120–122].

4.5. Nonhomologous Recombination. The nonhomologous recombination system or nonhomologous end-joining (NHR/NHEJ) system, also termed as “illegitimate recombination,” does not require homologous sequences; rather, it acts to rejoin the two end breaks and often results in deletions or mistakes and thus mutations. Although NHR is obviously error prone and degraded or even inappropriate ends may be rejoined, this repair system appears to be crucial in radio-induced DSB repair in plants [40, 43, 44]. Even though HR has been evidenced less efficient in DSB repair in plants, the information on NHR (or NHEJ) in plants is lacking [123]; thus, it is important to have insight into NHR pathway since genomic alterations in meristematic cells can be transferred to the offspring [104]. In somatic tissue, NHEJ has been evidenced as a major pathway for DSB repair. Since NHEJ-mediated rejoining of the broken ends is associated with deletions of various sizes and also with insertions of sequences (filler DNA) (that are often copied from sites close to the DSB) and sequence similarities are not required in NHEJ for the incorporation of filler DNA into the break; NHEJ does not preserve genetic information and genomic integrity at the break site [124]. NHEJ may also differ among species where an inverse correlation of deletion size to genome size has been postulated; thus, NHEJ significance in the genome size evolution has been advocated [125]. Details about the molecular-genetics of NHEJ in eukaryotes can be found elsewhere [126].
5. Conclusion and Future Perspectives

Plant nuclear DNA is an inherently unstable molecule and can be damaged spontaneously, metabolically, or by a number of stress factors. Though sunlight is obligatory for photosynthesis and survival of plants, it also represents one of the major threats to their genomic integrity. Sunlight contains energy rich UV-A (320–400 nm), UV-B (290–320 nm), and UV-C (280–100 nm) light. While UV-C is filtered out in the atmosphere, UV-B and UV-A can reach earth's surface. On the other hand, IR causes water radiolysis, which generates highly reactive hydroxyl radicals. DNA is the object of an attack by both UV and IR radiations leading to a number of alterations including SSBs and DSBs. The accumulation of such damages and unrecognized and unrepaired DNA damage may cause fatal mutations which in turn can reduce plant genome stability, growth, and productivity and also threaten the organism's immediate survival. Plants employ various strategies to either reverse, excise, or tolerate the presence of DNA damage products. The literature reviewed here reflected the paucity of information on the basic mechanisms underlying UV or IR mediated DNA damage and repair compared to bacteria, yeast, and mammalian systems. Both HR and NHR pathways-mediated facilitation of the programmed repair of DSBs have been evidenced. Thus, plants have become an ideal system for the identification of genes which are not accessible to classical genetic analysis in other systems (including mammalian model systems). Identification and characterization of UV/IR-sensitive mutants in different plant species are expected to achieve more insights into genetic recombination/manipulation in plants.

Conflict of Interests

The authors declare that there is no conflict of interests regarding the publication of this paper.

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References


[110] L. Liang, S. Flury, V. Kalck, B. Hohn, and J. Molinier, "CENTRIN2 interacts with the arabidopsis homolog of the human XPC protein (AtRAD4) and contributes to efficient synthesis-dependent repair of bulky DNA lesions," *Plant Molecular Biology*, vol. 61, no. 1–2, pp. 345–356, 2006.


